

United States Patent and Trademark Office



UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/598,736	06/21/2000	Toru Takayama	SEL 189	5820
7590 10/10/2006 Mark J Murphy COOK ALEX MCFARRON MANZO CUMMINGS & MEHLER LTD 200 West Adams Street Suite 2850 Chicago, IL 60606			EXAMINER	
			VU, HUNG K	
			ART UNIT	PAPER NUMBER
			2811	
			DATE MAILED: 10/10/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
Office Action Summary		09/598,736	TAKAYAMA ET AL.			
		Examiner	Art Unit			
		Hung Vu	2811			
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SH WHIC - Exter after - If NC - Failu Any I	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. Period for reply is specified above, the maximum statutory period ver to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICAT 36(a). In no event, however, may a reply will apply and will expire SIX (6) MONTHS, cause the application to become ABAND	TION. be timely filed from the mailing date of this communication. ONED (35 U.S.C. § 133).			
Status						
2a)⊠	Responsive to communication(s) filed on 29 Ju This action is FINAL . 2b) This Since this application is in condition for allowar closed in accordance with the practice under E	action is non-final. nce except for formal matters,	•			
Dispositi	on of Claims					
5)⊠ 6)⊠ 7)□ 8)□ Applicati 9)□ 10)□	Claim(s) 1-3,5,10-15,28-39 and 64-120 is/are page 4a) Of the above claim(s) is/are withdraw Claim(s) 28-39 is/are allowed. Claim(s) 1-3,5,10-15 and 64-120 is/are rejecte Claim(s) is/are objected to. Claim(s) are subject to restriction and/of the specification is objected to by the Examine The drawing(s) filed on is/are: a) according a cordinate for the drawing sheet(s) including the correct the oath or declaration is objected to by the Examine The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct the oath or declaration is objected to by the Examine The oath or declaration is objected to by the Examine Replacement drawing sheet(s) including the correct the oath or declaration is objected to by the Examine The oath of	wn from consideration. d. r election requirement. er. epted or b) objected to by the drawing(s) be held in abeyance. tion is required if the drawing(s) is	See 37 CFR 1.85(a). s objected to. See 37 CFR 1.121(d).			
Priority u	ınder 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.						
2) Notice 3) Information	t(s) be of References Cited (PTO-892) be of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO/SB/08) or No(s)/Mail Date	_	nary (PTO-413) ail Date nal Patent Application			

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 5 and 115 are rejected under 35 U.S.C. 102(b) as being anticipated by Oikawa et al. (PN 4,770,948, of record).

Oikawa et al. discloses, as shown in Figures 5 and 7, a semiconductor device, the semiconductor device comprising,

a wiring comprising tungsten form over a substrate (1), the wiring including a gate electrode (5) formed over a substrate (1),

wherein the wirings includes argon, and

wherein an amount of sodium contained within the wiring is equal to or less than 0.3 ppm.

Regarding claim 5, Oikawa et al. discloses the substrate comprises a silicon substrate.

Regarding claim 115, Oikawa et al. discloses the wiring comprises a tungsten film.

Application/Control Number: 09/598,736 Page 3

Art Unit: 2811

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all

obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the

manner in which the invention was made.

Claims 3, 10-11 and 13 rejected under 35 U.S.C. 103(a) as being unpatentable over

Oikawa et al. (PN 4,770,948, of record).

Regarding claims 3, 10-11, 13, although Oikawa et al. does not teach the thickness of the wiring,

the electrical resistivity and the internal stress, the line width, the resistance, as that claimed by

Applicants, however, it would have been obvious to one having ordinary skill in the art at the

time the invention was made to form the wiring having a desired thickness, resistivity, internal

stress, line width, or resistance, since it has been held that discovering an optimum value of a

result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205

USPQ 215 (CCPA 1980).

3. Claim 12 is rejected under 35 U.S.C. 103(a) as being unpatentable over Oikawa et al. (PN

4,770,948, of record) in view of Ikeda et al. (JP8-153722, of record)

Oikawa et al. discloses the invention substantially as claimed, including the device as cited in the

rejection above. Oikawa et al. does not disclose the wiring is used as a gate electrode of a TFT.

However, Ikeda et al. discloses the wiring is used as a gate electrode of a TFT or MOS with a

semiconductor film (104). Note Figure 13 of Ikeda et al.. Therefore, it would have been obvious

to one of ordinary skill in the art at the time the invention was made to form the wiring of

Art Unit: 2811

Oikawa et al. and Prall et al. as the gate electrode for the TFT, such as taught by Ikeda et al. in order to increase the circuitry density.

Page 4

Claim 2 and 64-92, 103-114, 116-120 are rejected under 35 U.S.C. 103(a) as being 4. unpatentable over Oikawa et al. (PN 4,770,948, of record) in view of Okazaki (PN 5,477,359). Oikawa et al. discloses the invention substantially as claimed, including the device as cited in the rejection above. Oikawa et al. does not disclose the substrate is a glass substrate and the base insulating film comprising silicon nitride or silicon oxynitride. However, Okazaki discloses a substrate (301) is a glass substrate and a base insulating film (304) comprising silicon nitride or silicon oxynitride. Note Figure 14 of Okazaki. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to form the substrate of Oikawa et al. as the glass substrate and the base insulating film comprising silicon nitride or silicon oxynitride, such as taught by Okazaki in order to improve the circuit performance.

Regarding claims 65-67, 84-86, 106-108, although Oikawa et al. and Okazaki do not disclose other inert element (Xe or Kr) is contained within the wiring at an amount equal to or less than 0.1 atom%. However, it would have been obvious to one having ordinary skill in the art at the time the invention was made to form the wiring having a desired amount of other inert element, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Art Unit: 2811

Regarding claims 68, 69 and 71, 74, 77, 78, 80, 83, 87, 88, 90, 103, 109, 110, 112, although Oikawa et al. and Okazaki do not teach the thickness of the wiring, the line width, the internal stress, the resistance, as that claimed by Applicants, however, it would have been obvious to one having ordinary skill in the art at the time the invention was made to form the wiring having a desired thickness, line width, internal stress, or resistance, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Regarding claim 70, although Oikawa et al. and Okazaki disclose the wiring is used as a gate electrode of TFT.

Regarding claims 14, 15, 72, 73, 81, 82, 91, 92, 113, 114, Oikawa et al. and Okazaki disclose the semiconductor device is an active matrix type liquid crystal display, an active matrix type EL display, or an active matrix type EC display, or a video camera, a digital camera, a projector, a goggle type display, a car navigation system, a personal computer, or a portable information terminal.

5. Claims 93-102 are rejected under 35 U.S.C. 103(a) as being unpatentable over Oikawa et al. (PN 4,770,948, of record) in view of Okazaki (PN 5,477,359) and further in view of Prall et al. (PN 5,341,016, of record)).

Oikawa et al. and Okazaki disclose the claimed invention including the semiconductor device, as explained in the rejection above. Oikawa et al. and Okazaki do not disclose an insulating film

Application/Control Number: 09/598,736

Art Unit: 2811

comprising SiOxNy formed over the wiring. However, Prall et al. discloses an insulating film (21) comprising SiOxNy formed over the wiring. Note Figures 5 and 7 of Prall et al.. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to form a cap layer over the wiring of Oikawa et al. and Okazaki, such as taught by Prall et al. in order to increase the adhesion of the wiring and to protect the wiring during etching.

Regarding claims 94-96, although Oikawa et al., Okazaki and Prall et al. do not disclose other inert element (Xe or Kr) is contained within the wiring at an amount equal to or less than 0.1 atom%. However, it would have been obvious to one having ordinary skill in the art at the time the invention was made to form the wiring having a desired amount of other inert element, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Regarding claims 97, 98, 100, although Oikawa et al., Okazaki and Prall et al.not teach the thickness of the wiring, the line width, the internal stress, the resistance, as that claimed by Applicants, however, it would have been obvious to one having ordinary skill in the art at the time the invention was made to form the wiring having a desired thickness, line width, internal stress, or resistance, since it has been held that discovering an optimum value of a result effective variable involves only routine skill in the art. In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980).

Regarding claim 99, Oikawa et al., Okazaki and Prall et al. disclose the wiring is used as a gate

Application/Control Number: 09/598,736 Page 7

Art Unit: 2811

electrode of TFT.

Regarding claims 101, 102, Oikawa et al., Okazaki and Prall et al. disclose the semiconductor device is an active matrix type liquid crystal display, an active matrix type EL display, or an active matrix type EC display, or a video camera, a digital camera, a projector, a goggle type display, a car navigation system, a personal computer, or a portable information terminal.

Allowable Subject Matter

6. Claims 28-39 are allowed.

Response to Arguments

7. Applicant's arguments filed 06/29/06 have been fully considered but they are not persuasive.

It is argued, at page 3 of the Remarks, that Oikawa discloses a concentration of sodium in a target, not within the metal film of the wiring, therefore, the sodium concentration of the target is not the same as the sodium concentration in the metal film of the wiring. The Examiner is agreed. In fact, the sodium concentration should be less than that. However, the sodium concentration still meets the recited limitation of "equal to or less than". Note that the arguments of counsel cannot take the place of evidence in the record. In re Schulze, 346 F.2d 600, 602, 145 USPQ 716, 718 (CCPA 1965); In re Geisler, 116 F.3d 1465, 43 USPQ2d 1362 (Fed. Cir. 1997) ("An assertion of what seems to follow from common experience is just attorney argument and not the kind of actual evidence that is required to rebut a prima facie case of obviousness."). See

Art Unit: 2811

MPEP 716.01(c) for examples of attorney statements which are not evidence and which must be supported by an appropriate affidavit or declaration.

It is argued, at page 4 of the Remarks, that Oikawa does not disclose a sodium concentration in other metals, such as tungsten. This argument is not convincing because Oikawa discloses, as shown in Col. 7, lines 56-65, that other metals can be used, such as tungsten.

Conclusion

8. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hung Vu whose telephone number is (571) 272-1666. The examiner can normally be reached on Tuesday to Friday 6:00-4:30.

Application/Control Number: 09/598,736 Page 9

Art Unit: 2811

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on (571) 272 - 1732. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Vu

September 30, 2006

Hung Vu

Primary Examiner